



INFORMATION CITED BY APPLICANTS THAT MAY BE MATERIAL TO THE  
PROSECUTION OF THE SUBJECT APPLICATION

Applicants: L.W. Graham et al.

Attorney Docket No.: SEMT116060

Application No.: 09/429,446

Group Art Unit: 1741

Filed: October 28, 1999

Examiner: W. Leader

Title: METHOD, CHEMISTRY, AND APPARATUS FOR NOBLE METAL  
ELECTROPLATING ON A MICROELECTRONIC WORKPIECE

U.S. PATENT DOCUMENTS

*Examiner	Cite Initials	Cite No.	Document No.	Kind Code	Date (mm/dd/yyyy)	Name
	WL	U15	4,243,532		01/06/1981	Tsuda et al.
	WL	U16	5,232,328		08/03/1993	Owczarz et al.
	WL	U17	5,344,491		09/06/1994	Katou
	WL	U18	5,484,518		01/16/1996	Goldberg
	WL	U19	5,731,678		03/24/1998	Zila et al.

Examiner

Date Considered

William Leader

2/2002

\*Examiner: Initial if reference considered, whether or not citation is in conformance with M.P.E.P. § 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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